This article was downloaded by:

On: 27 January 2011

Access details: Access Details: Free Access

Publisher *Taylor & Francis*

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH, UK



Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

Silylation of Alcohols and Phenols Using Hexamethyldisilazane Catalyzed by *N,N'*-Diiodo-*N,N'*-1,2-ethanediyl Bis(*p*-toluenesulfonamide) Under Solvent-Free and Microwave Conditions

Ramin Ghorbani-Vaghei^a; Seyedeh Mina Malaekehpoor^b

^a Department of Organic Chemistry, Faculty of Chemistry, Bu-Ali Sina University, Hamadan, Iran ^b Department of Chemistry, Payame Noor University, Hamadan, Iran

Online publication date: 24 February 2010

To cite this Article Ghorbani-Vaghei, Ramin and Malaekehpoor, Seyedeh Mina(2010) 'Silylation of Alcohols and Phenols Using Hexamethyldisilazane Catalyzed by N,N-Diiodo-N,N-1,2-ethanediyl Bis(p-toluenesulfonamide) Under Solvent-Free and Microwave Conditions', Phosphorus, Sulfur, and Silicon and the Related Elements, 185: 3, 582 — 587

To link to this Article: DOI: 10.1080/10426500902849581 URL: http://dx.doi.org/10.1080/10426500902849581

PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

Phosphorus, Sulfur, and Silicon, 185:582-587, 2010

Copyright © Taylor & Francis Group, LLC ISSN: 1042-6507 print / 1563-5325 online DOI: 10.1080/10426500902849581



SILYLATION OF ALCOHOLS AND PHENOLS USING HEXAMETHYLDISILAZANE CATALYZED BY N,N'-DIIODO-N,N'-1,2-ETHANEDIYL BIS(p-TOLUENESULFONAMIDE) UNDER SOLVENT-FREE AND MICROWAVE CONDITIONS

Ramin Ghorbani-Vaghei¹ and Seyedeh Mina Malaekehpoor²

¹Department of Organic Chemistry, Faculty of Chemistry, Bu-Ali Sina University, Hamadan, Iran

N,N'-Diiodo-N,N'-1,2-ethanediyl bis(p-toluenesulfonamide) (NIBTS) is an effective catalyst for the silylation of alcohols and phenols using hexamethyldisilazane under solvent-free and microwave conditions.

Supplemental materials are available for this article. Go to the publisher's online edition of Phosphorus, Sulfur, and Silicon and the Related Elements to view the free supplemental file.

Keywords Alcohols; HMDS; microwave irradiation; NIBTS; phenols; silylation; solvent-free

INTRODUCTION

The silylation of organic compounds is widely applied for the protection of hydroxyl group in organic synthesis. ¹⁻³ Several methods are available for silylation of a hydroxy functional group using a variety of silylating agents. ^{2,4-6} 1,1,1,3,3,3-Hexamethyldisilazane (HMDS) is convenient as a silylating agent, because it is a stable, commercially available, cheap reagent and gives ammonia as the only byproduct. In addition, silylation with HMDS is nearly neutral and does not need special precautions. However, the main drawback of HMDS is its poor silylating power, which needs forceful conditions and long reaction times in many cases. ⁷ A variety of catalysts such as (CH₃)₃SiCl, ⁸ sulfonic acids, ⁹ ZnCl₂, ¹⁰ K-10 montmorillonite, ¹¹ LiClO₄, ¹² H₃PW₁₂O₄₀, ¹³ iodine, ¹⁴ nitrogen-ligand complexes of metal chlorides, ¹⁵ zirconium sulfophenyl phosphonate, ¹⁶ TBAPINO, ¹⁷ ZrO(OTf)₂, ¹⁸ Fe(F₃CCO₂)₃, ¹⁹ ZnO, ²⁰ NaHSO₄·SiO₂, ²¹ sulfonic acid-functionalized ordered nanoporous silica, ²² alumina sulfuric acid, ²³ silica sulfuric acid, ²⁴ indium tribromide, ²⁵ and KBr²⁶ have

Received 2 February 2009; accepted 25 February 2009.

We are thankful to Bu-Ali Sina University, Center of Excellence and Development of Chemical Methods (CEDCM) for financial support.

Address correspondence to Ramin Ghorbani-Vaghei, Department of Organic Chemistry, Faculty of Chemistry, Bu-Ali Sina University, Hamadan, Iran. E-mail: rgvaghei@yahoo.com

²Department of Chemistry, Payame Noor University, Hamadan, Iran

NIBTS

Figure 1 Structure of N,N'-diiodo-N,N'-1,2-ethanediylbis(p-toluenesulfonamide).

been developed for the activation of HMDS. Although these procedures provide an improvement, many of these catalysts need long reaction times, drastic reaction conditions, tedious workup, or are moisture-sensitive or expensive. Hence, introduction of new methods to circumvent these problems are still in demand.

RESULTS AND DISCUSSION

With our interest in the application of N,N'-diiodo-N,N'-1,2-ethanediyl bis(p-toluene sulfonamide) (NIBTS)²⁷ (Figure 1) as a mild catalyst in organic synthesis, in this article we report a simple method for the silylation of alcohols and phenols in the presence of NIBTS as an effective catalyst with HMDS under solvent-free and microwave irradiation conditions.

The reaction of alcohols and phenols with HMDS in the presence of NIBTS brings about *o*-silylation without side-product formation (Scheme 1).

ROH
$$\frac{\text{HMDS (2mmol), NIBTS (0.08 mmol, 0.05 g)}}{\text{Solvent-free or MW}}$$
 ROSiMe₃

R = Primary, secondary, tertiary alkyl, and benzylic

Scheme 1

First we carried out the reaction of benzyl alcohol with HMDS in the presence of NIBTS under solvent-free and microwave conditions (see Scheme S1, available online in the Supplemental Materials). We found a good yield obtained in 0.05 g (8 mol%) of NIBTS in solvent-free and microwave irradiation conditions (Table I). As shown in Table II, treatment of a variety of alcohols and phenols with HMDS in the presence of

Table I The effect of the amount of NIBTS on the reaction of benzyl alcohol and HMDS under solvent-free and MW conditions

	Solvent-free		Microwave		
NIBTS (g)	Time (min)	Yield (%)	Time (min)	Yield (%)	
0.01	5	Very low	1	Very low	
0.02	5	75	1	60	
0.03	5	75	1	80	
0.04	5	86	1	93	
0.045	5	90	1	96	
0.05	5	95	1	98	

 $\textbf{Table II} \hspace{0.2cm} \textbf{Silylation of alcohols and phenols using HMDS in the presence of NIBTS under solvent-free and MW conditions$

Entry	Substrate	Product	Yield (%)/ Time (min)	Yield (%)/ Time (min)	References
1	CH ₂ OH	CH ₂ OSiMe ₃	95/5	98/1	18
2	OCH ₃	CH ₂ OSiMe ₃	96/12	100/1	18
3	OH CHCH3	OCH ₃ OSiMe ₃ CHCH ₃	80/40	87/16	18
4	CH ₂ CH ₂ OH	CH ₂ CH ₂ OSiMe ₃	94/12	96/3	18
5	~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~~	OSiMe ₃	80/60	90/10	18
6	OH CH₂OH	CH ₂ OSiMe ₃	93/9	96/1	18
7	Cl CH ₂ OH Br	CI CH ₂ OSiMe ₃ Br	95/10	97/4	28
8	ОН	OSiMe ₃	80/219	88/1	18
9	СН₃СНСН₂ОН	CH ₃ CHCH ₂ OSiMe ₃	92/30	96/7	28
10	OH	OSiM e ₃	92/15	95/5	18
11	CH ₂ OH	CH ₂ OSiMe ₃	88/230	81/12	28
12	Ŭ OH	OSiMe ₃	76/115	87/10	14
				(Continued o	n next page)

Table II Silylation of alcohols and phenols using HMDS in the presence of NIBTS under solvent-free and MW conditions (*Continued*)

Entry	Substrate	Product	Yield (%)/ Time (min)	Yield (%)/ Time (min)	References
13	OH	OSiMe ₃	88/35	90/6	18
14	OH	OSiMe ₃	87/46	94/3	29
15	ОН	OSiM e ₃	90/110	95/1	29
16	Cl OH H ₃ CO	Cl OSiM e ₃	84/24	93/6	30
17	CH ₂ CH ₂ OH	H ₃ CO CH ₂ CH ₂ OSiM e ₃	86/130	80/8	18
18	OH	OSiM e ₃	67/440	90/12	28
19	CH ₂ SH	CH ₂ SSiMe ₃	12/— ^a	10/— ^a	_
20	CH ₂ SH	CH ₂ SSi M e ₃	12/— ^a	30/— ^a	_

^aNo reaction.

NIBTS gave the corresponding trimethylsilyl ethers in good to excellent yields. Primary and secondary benzylic alcohols and phenols were all protected using NIBTS in excellent yields under solvent-free or microwave conditions. Primary benzylic alcohols (with electron-releasing and electron-withdrawing groups) and aliphatic (linear, cyclic) alcohols were trimethylsilylated with excellent yield. We also found that hindered tertiary alcohols such as adamantanol (Table II, entry 13) were silylated in high yields. We found that NIBTS was not suitable for the silylation of thiols under solvent-free and microwave conditions (Table II, entries 18 and 19), as this reagent converted thiols to disulfides instead of to silyl thiols (Scheme S2, available online in the Supplemental Materials).

Our experiments also indicated that NIBTS is a reusable catalyst; after five runs, the catalytic activity was almost the same as fresh catalyst. Thus, after the successful silylation of benzyl alcohol in the first run under microwave irradiation (98%), the *N*,*N'*-diiodo-*N*,*N'*-1,2-ethanediyl bis(*p*-toluenesulfonamide) (NIBTS) catalyst was subjected to a second run reaction, from which it gave the product in 98% yield. The average chemical yield for five consecutive runs was 96% (see Table S1 online in the Supplemental Materials).

In conclusion, we have introduced the catalytic reagent N,N'-diido-N,N'-1,2-ethanediyl bis (p-toluenesulfonamide) (NIBTS) as the activator of HMDS for the protection of a various alcohols and phenols under solvent-free or microwave irradiation conditions. The catalyst is heterogeneous, non-corrosive, and environmentally benign. Isolation of products involved simple extraction and evaporation of the solvent.

EXPERIMENTAL

General Method for the Silylation of Alcohols and Phenols Using HMDS and NIBTS Under Solvent-Free Conditions

Alcohol or phenol (1 mmol), NIBTS (0.05 g, 0.08 mmol), and HMDS (2 mmol) were added to a mortar, and the mixture was pulverized vigorously with a pestle. The reaction was monitored by TLC (8:2, *n*-hexane:acetone). After completion of the reaction, CH₂Cl₂ (15 mL) was added, and the catalyst was removed by filtration. The organic phase was dried over anhydrous Na₂SO₄ (1 g). Evaporation of the solvent under reduced pressure gave the product. Further purification was achieved by distillation or recrystallization to afford pure silyl ethers (Table I).

General Method for the Silylation of Alcohols and Phenols Using HMDS and NIBTS Under Microwave Irradiation

Alcohol or phenol (1 mmol), NIBTS (0.05 g, 0.08 mmol), and HMDS (2 mmol) were added to a round-bottomed flask (25 mL). The flask was placed in a bath containing SiO₂ to enable absorption of additional microwave irradiation. The flask was irradiated in a microwave oven at a power output with (900 W) (LG Co. microwave, 230 V \sim 50 Hz, RF output 900 W). After completion of the reaction [1–16 min, Table I, monitored by TLC (8:2, *n*-hexane:acetone)], CH₂Cl₂ (15 mL) was added, and the catalyst was removed by filtration. The organic phase was dried over anhydrous Na₂SO₄ (1 g). Evaporation of the solvent under reduced pressure gave the product. Further purification was achieved by distillation or recrystallization to afford pure silyl ethers (Table I).

REFERENCES

- R. Tacke and H. Linon, *Bioorganosilicon Chemistry*, S. Patai and Z. Rappoport, Eds. (Wiley, New York, 1989), Chap. 18.
- 2. A. E. Pierce, Silylation of Organic Compounds (Pierce Chemical, Rockford, IL, 1968).
- M. M. Demina, A. A. Velikanov, A. S. Medvedeva, O. I. Margorskaya, and M. G. Voronkov, Pat. SSSR 1833392 (1991); Bull. Izobret., 29, 146 (1993).
- 4. M. V. Kashutina, S. I. Ioffe, and V. A. Tartakavskii, Usp. Khim., 44, b620 (1975).
- 5. G. A. Olah, B. G. Gupta, S. C. Narang, and R. Malhotra, *J. Org. Chem.*, 44, 4272 (1979) and references cited therein.
- 6. M. Lalonde and T. H. Chan, Synthesis, 817 (1985).
- 7. C. A. Bruynes and T. K. Jurriens, J. Org. Chem., 47, 3966 (1982).
- 8. P. Gauttret, S. El-Ghamarti, A. Legrand, D. Coutrier, and B. Rigo, *Synth. Commun.*, **26**, 707 (1996).
- 9. A. G. Goldschmidt, German Patent 2 758884; Chem. Abstr., 90, 6530c (1979).
- 10. H. Firouzabadi and B. Karimi, Synth. Commun., 23, 1633 (1993).
- 11. Z. H. Zhang, T. S. Li, F. Yang, and C. G. Fu, Synth. Commun., 28, 3105 (1998).

- 12. M. R. Saidi and N. Azizi, Organometallics, 23, 1457 (2004).
- 13. H. Firouzabadi, N. Iranpoor, K. Amani, and F. Nowrouzi, J. Chem. Soc., Perkin Trans., 1, 2601 (2002).
- 14. B. Karimi and B. Golshani, J. Org. Chem., 65, 7228 (2000).
- 15. H. Firouzabadi, A. R. Sardarian, Z. Khayat, B. Karimi, and S. Tangestaninejad, *Synth. Commun.*, **27**, 2709 (1997).
- 16. M. Curini, F. Epifano, M. C. Marcotullio, and O. Rosati, Synth. Commun., 29, 541 (1999).
- 17. M. G. Dekamin, J. Mokhtari, and M. R. Naimi-Jamal, Catal. Commun., 10, 582 (2009).
- M. Moghadam, S. Tangestaninejad, V. Mirkhani, and I. Mohammadpoor-.Baltork, J. Organomet. Chem., 693, 2041 (2008).
- H. Firouzabadi, N. Iranpoor, A. A. Jafari, and M. R. Jafari, J. Organomet. Chem., 693, 2711 (2008).
- 20. H. R. Shaterian and M. Ghashang, *Phosphorus, Sulfur, and Silicon*, **182**, 1645 (2007).
- H. R. Shaterian, R. Doostmohammadi, M. Ghashang, and M. Rahmani, *Phosphorus, Sulfur, and Silicon*, 183, 3127 (2008).
- 22. D. Zareyee and B. Karimi, Tetrahedron Lett., 48, 1277 (2007).
- H. R. Shaterian, F. Khorami, A. Amirzadeh, M. Ghashang, and A. Hosseinian, *Phosphorus*, Sulfur, and Silicon, 183, 2584 (2008).
- 24. H. Ghafuri, B. Eftekhari-Sis, and M. M. Hashemi, Synth. Commun., 37, 1363 (2007).
- J. S. Yadav, B. V. S. Reddy, A. K. Basak, G. Baishya, and A. Venkat Narsaiah, *Synthesis*, 22, 3831 (2006).
- 26. F. Shirini and E. Mollarazi, Synth. Commun., 36, 1109 (2006).
- 27. R. Ghorbani-Vaghei, Tetrahedron Lett., 44, 7529 (2003).
- 28. F. Shirini and E. Mollarazi, Catal Commun., 8, 1393 (2007).
- 29. N. Azizi, R. Yousefi, and M. R. Saidi, J. Organomet. Chem., 691, 817 (2006).
- A. Khazaei, M. A. Zolfigol, A. Rostami, and A. Ghorbani Choghamarani, *Catal. Commun.*, 8, 543 (2007).